

03-07-02

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COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231

Docket No. CS01-067

Sir:

Transmitted herewith for filing is the Patent Application of:

Inventor: DONG ZHONG, YUN LING TAN, CHEW HOE ANG, JIA ZHEN ZHENG

IMPROVED ULTRA-THIN GATE OXIDE THROUGH POST DECOUPLED PLASMA NITRIDATION ANNEAL

U.S. PTO
10/09/1983
03/06/02

Enclosed are:

- ☒ 2 sheets of drawing(s) - formal.
- ☒ An assignment of the invention to **Chartered Semiconductor Manufacturing Ltd.**
- ☐ An associate power of attorney ☐ Applicant claims small entity status
- ☐ Request & Certification under 35 USC 122(b) (2) (b) (i)

The filing fee has been calculated as shown below:

	(Col. 1)	(Col. 2)	OTHER THAN A SMALL ENTITY	
FOR:	NO. FILED	NO. EXTRA	RATE	FEE
BASIC FEE				\$ 740.
TOTAL CLAIMS	15 -20=	0	x 18 =	\$ 0.
INDEP CLAIMS	2 -3=	0	x 84 =	\$ 0.
MULTIPLE DEPENDENT CLAIM PRESENTED			+ 260 =	
SUB TOTAL				\$ 740.
ASSIGNMENT				\$40.
TOTAL				\$ 780.

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